Novel insights into the design of stretchable electrical systems

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Soft electronics have recently gathered considerable interest because of their biomechanical compatibility. An important feature of deformable conductors is their electrical response to strain. While development of stretchable materials with high gauge factors has attracted considerable attention, there is a growing need for stretchable conductors whose response to deformation can be accurately engineered to provide arbitrary resistance-strain relationships. Rare studies addressing this issue have focused on deterministic geometries of single rigid materials, limiting the scope of these strategies. We introduce the novel concept of periodic stretchable patterns combining multiple conductive materials to produce tailored responses. Using shortest path algorithms, we establish a computationally efficient selection method to obtain the required resistance-strain relationship. Using this algorithm, we identify and experimentally demonstrate constant resistance-strain responses up to 50% elongation using a single microtextured material. Last, we demonstrate counterintuitive sinusoidal responses by integrating three materials, with interesting applications in sensing and soft robotics.

INTRODUCTION

The integration of deformable yet conductive materials has paved the way for a new generation of truly conformable devices that can be seamlessly integrated over biological tissues. The applications of these stretchable conductive materials and structures include not only sensing (1–4) but also actuation in soft robotics (5–7) and stretchable optics (2, 8, 9). Thus far, a large focus has been placed on maximizing system response to deformation, such as deformation sensors using deterministic geometries for demultiplied sensitivity (10, 11) or development of extremely soft yet conductive hydrogels (10, 12–13) in soft robotics. In specific situations, however, it may be desirable to engineer a precise response to external deformation. This is the case of stretchable interconnects, which interface different rigid chips within a stretchable matrix. Given that many electrical devices such as transistors or amplifiers rely on constant current sources to function, stretchable interconnects would benefit from minimal current variation with deformation to connect these various chips under strain. In a broader manner, providing arbitrary resistance-strain behavior has remained an open problem.

Microstructure offers the possibility to tailor the response in resistance with strain beyond classical deformation theory of homogeneous materials. Atypical resistive behavior with strain has been observed in various system near-percolation composites, such as carbon nanotube–based (14, 15) or silver nanowire–based (16, 17) composites. Until now, however, works investigating these systems have remained focused on randomly distributed networks (18), while the leverage over resistance-strain behavior has remained limited to composite loading. The lack of order at the meso- or macroscopic scale inevitably limits the variety of resistance response. Responses with negative gauge factor have also been observed in micro- or nanostructured liquid metal thin films, but the inherent randomness of the structure again limits tuning possibilities (19, 20). Recent works using deterministic geometries of folded lines of a single rigid metal, semiconductors, or rigid composite (21, 22) have achieved constant resistance-strain relationships. However, such an approach provides no tunability and remains fragile, thus limited in strain. Moreover, it induces inevitable challenges to rigorously identify the elastic and plastic mechanics of these composite materials.

While recent studies have pointed to the role of orientation in one-dimensional (1D) nanomaterials to explain complex resistance response with strain (17), no analytical approach has been proposed to understand the link between microstructure and resistance-strain behavior in ordered 2D systems.

In this work, we propose a new methodology introducing periodic arrays in stretchable conductive systems to engineer predefined resistance-strain relationships. We first develop a code to accurately calculate the resistance of an $N \times N$ grid of 2D resistors with two distinct conductivities. Using this model, we show that the effective medium approach is inappropriate for dense periodic arrays with increasing conductivity contrast in stretchable electrical systems. We then demonstrate how, by fine-tuning the periodic arrangement and the choice of materials, one can design resistance-strain relationships with completely tunable gauge factor from positive to negative passing through zero. To limit computing cost, we further introduce the concept of shortest resistive path to understand the evolution of resistance during elongation. Given an initial set of microstructures and materials, this approach allows us, in particular, to provide at reduced cost the best combination of materials and microstructure to achieve a targeted response. Using an optimization algorithm, we identify by simulation the best microstructures to provide a constant resistance over extensions up to 50%. We further experimentally demonstrate these microstructures (deviation $<3\%$) using a single microtextured conductive stretchable material. Last, by integrating three distinct sets of materials, we discuss the possibility to deviate from purely linear responses and demonstrate counterintuitive sinusoidal resistance-strain responses, which could find interesting applications in sensing and soft robotics.
RESULTS AND DISCUSSION

Breakdown of the effective medium approach in near-percolation bi-conductive systems

Continuum mechanics provides a well-established framework linking resistance of a homogeneous material with deformation through the gauge factor \( G \) (23)

\[
G = \frac{\Delta R/R_0}{\Delta L/L_0} = 1 + 2\nu + \frac{\Delta\rho/\rho_0}{\varepsilon}
\]

where \( \nu \) is the Poisson ratio, \( \varepsilon \) is the strain, \( \rho_0 \) is the initial material resistivity, and \( \Delta\rho \) is the material relative change in resistivity. The first contribution to the gauge factor, also known as the geometrical contribution \((1 + 2\nu)\), is fixed by the material’s properties. Although the Poisson ratio can vary largely between materials, common elastomeric materials that allow large reversible deformations are typically incompressible \((\nu \sim 0.5)\) (23), limiting the tunability of the geometrical term. The second contribution \( \left( \frac{\Delta\rho/\rho_0}{\varepsilon} \right) \) accounts for piezoresistive effects and can become dominant in some materials (as high as 200 in p-type [110] single crystalline silicon) (24, 25). This term is also strongly dependent on the choice of materials and usually occurs in systems that cannot sustain reversibly large deformations (24, 26, 27).

The approach detailed above is commonly used for materials that can be considered homogeneous. Let us now consider a composite that blends two different materials (called materials A and B). This material is hence heterogeneous, typically with small inclusions of material A dispersed within a matrix of material B. To assess the resistance of such a material under deformation, one could resort to the previous homogeneous framework by considering the effective resistance of the composite \( R_{\text{eff}} \), i.e., the resistance of each material pondered by their respective share of the total composite volume

\[
R_{\text{eff}}(\varepsilon) = X_A R_A(\varepsilon) + X_B R_B(\varepsilon)
\]

where \( X_A \) and \( X_B \) are the volume fractions of materials A and B, respectively, and \( R_A \) and \( R_B \) are the resistance associated to materials A and B. The effective medium approach is, however, no longer appropriate when the small inclusions of materials increase in size and the system approaches the percolation threshold. To assess the accurate resistance (called equivalent resistance \( R_{\text{eq}} \) in the rest of this work) in 2D composites, we develop a model that evaluates the resistance of a random 2D resistor network made of two distinct types of resistors (total size \( N \times N \)). Kirchhoff’s rule states that, for every site between four resistors, the sum of the currents is zero, defining a solvable linear set of \( N^2 - 1 \) equations. By injecting and extracting a known current at predefined locations, the resistance of the network between these two points can be evaluated. Given a fixed microstructure, the 2D resistor network hence allows one to calculate the accurate equivalent resistance for arbitrarily complex grids of reasonable size using direct matrix inversion method (see Fig. 1A and section S1). We define material A as the background low-conductivity material (in dark red) and material B as the isolated squares of high conductivity (in light red).

To evaluate the deviation of \( R_{\text{eff}} \) with regard to \( R_{\text{eq}} \), we now consider a heterogeneous film microstructure composed of a periodic square array of material A with conductivity \( \sigma_A \) onto a substrate of material B with a conductivity \( \sigma_B \) (see Fig. 1, B and C), without any elongation at this point. In the proposed framework, only the conductivity ratio is varied, and the absolute conductivities \( \sigma_A \) and \( \sigma_B \) can therefore span over an arbitrary range. The square width \( W \) is gradually increased, while the period \( P \) is kept fixed. Contacts of infinite conductivity are applied on the two edges of the network to calculate the equivalent resistance \( R_{\text{eq}} \) (see section S2). For a fixed conductivity ratio \( \gamma = \frac{\sigma_A}{\sigma_B} > 1 \), an increase in the ratio \( W/P \) leads to a stronger deviation between effective resistance \( R_{\text{eff}} \) and actual resistance \( R_{\text{eq}} \), with maximal values reached for \( W/P \) in the range of 0.6 to 0.8 (see Fig. 1B). Keeping a fixed ratio \( W/P = 0.8 \), an increase in the conductivity ratio from 1 to 9 amplifies the deviation between \( R_{\text{eff}} \) and \( R_{\text{eq}} \) up to 35%. This deviation highlights the inadequacy of the effective medium approach in composite systems near percolation. For the rest of this work, we focus on direct evaluation of equivalent resistance to accurately determine the resistance of 2D resistor networks. We also neglect any piezoresistive behavior for both materials given the strains involved.

The breakdown of the effective medium approach is further validated by experiment using a tailored copper foil–conductive polymer composite (see section S3). The frequency-dependent response of such an assembly shows stable response up to 10 MHz (see section S4). Tailored material schemes with stable responses beyond 10 MHz could bear substantial interest in antenna devices (typical operation range, 13.56 MHz to 2.4 GHz) (28).

2D resistor networks for accurate response calculation under strain

Next, using the introduced model, we study the resistance evolution of the 2D composite under tensile deformation. We first focus on the resistance-strain relationship parallel to the tensile axis. For the periodic square array shown in Fig. 2A (i), an increase in conductivity ratio essentially induces negligible change in the resistance-strain curve. Adapting the structure with particular order can change this behavior in counterintuitive ways. By introducing a shift in the structure (Fig. 2, B and C) along the elongation direction, the observed response deviates from the linearly increasing resistance-strain relationship with an increase in conductivity ratio. This behavior is not present when the periodic shift is introduced perpendicular to the elongation direction. This evolution of resistance can be understood through a simple compromise. As the sample is deformed, high conductivity regions become more separated along the tensile axis, creating more resistive current pathways. This effect is counterbalanced by the compression perpendicular to the stretching direction, which creates additional conductive current pathways (see Fig. 3A for a detailed illustration). The interplay between these two competing phenomena define the actual global resistance change parallel to the tensile axis. Meanwhile, the resistance perpendicular to the tensile direction is exclusively driven by the reduction in distance transversally between high conductivity region, accounting for the continuous decrease in resistance. Varying the conductivity ratio can allow gauge factor switching at will from negative to positive passing through zero for linear arrays (Fig. 2, B and C). We hence identify a particular set of structures whose resistance is insensitive to strain under extended elongation.

The shortest path approach

The reverse problem, i.e., determining the proper combination of materials and microstructures to yield a desired resistance-strain response, is a relevant technological problem that requires a link
between microstructural parameters, strain and resistivity. Given a library of materials and microstructures (discretized in a mesh of size \( N \times N \)), a first brute force approach could consist of scanning through the various combinations of the library elements using the direct resistance calculation method detailed above. This approach may, however, prove computationally expensive given the \( N^3 \) complexity associated to matrix inversion. An alternative approach consists of simplifying the 2D resistor model into a reduced set of privileged resistor paths, corresponding to the shortest resistive paths for the current.

Let us now consider a microstructure where all the electrical current flows through a reduced set of shortest paths (see Fig. 3, A and B). Using Yen's shortest path algorithm (29), we can associate a cost to each shortest path, which helps discriminate which paths contribute most to current flow (see section S5). In the particular case of the structure shown in Fig. 3 (A and B), two paths (named Path 1 and Path 2) minimize the resistance to current at 0% strain. Additional shortest paths all show costs superior by a factor of at least 2 and are therefore further neglected. Paths 1 and 2 determined by Yen's algorithm include (i) a first shortest path set (named Path 1, in green), made of the straight lines connecting the two contacts through the regions of lowest conductivity, and (ii) a second shortest path set (named Path 2, in blue), made of the paths connecting transversally consecutive lowest-conductivity regions. We now make the assumption that each path acts as a closed channel for current: Current can only flow in or out at the extremities, i.e., the contacts. In this case, an equivalent resistance associated to each path \( R_{\text{Path } 1} \) (resp. \( R_{\text{Path } 2} \)) can be evaluated by treating all consecutive resistor elements as a series assembly. By distinguishing elementary pathways situated parallel (\( // \)) or perpendicular (\( \perp \)) to the applied strain, a direct link between microstructural parameters and strain appears

\[
R_{\text{Path } j} = \sum_{i \in \text{Path } j} \sum_{i \in \text{Path } j} f_i^j (p_i, L_i, S_i, \varepsilon, v, G_i^j) + \sum_{i \in \text{Path } j} f_i^j (p_i, L_i, S_i, \varepsilon, v, G_i^j) \tag{3}
\]

where \( p_i \) represents the resistivity of the \( i \)th element of path \( j \), \( L_0 \) is its length along the current direction, \( S_0 \) is its cross section perpendicular to the current direction, \( \varepsilon \) is the deformation along the tensile deformation axis, and \( v \) is the associated Poisson ratio. \( f_i^// \) (resp. \( f_i^\perp \)) represents the \( i \)th elementary resistance along the shortest path parallel (resp. perpendicular) to the applied strain, and \( G_i^// = L_i^// / W_i^// \) (resp. \( G_i^\perp = L_i^\perp / W_i^\perp \)) is a geometrical factor to take into account the actual width \( W \) and length \( L \) of the shortest path along the direction parallel (resp. perpendicular) to the tensile deformation (see section S5 for full description). In the particular case of a homogeneous isotropic conductive material such as liquid metal, \( f_i^// \) and \( f_i^\perp \) can be explicitly expressed:

\[
f_i^// = G_i^// \frac{L_i^//}{S_i^//} (1 + \varepsilon)^{1 + 2\varepsilon} \\
\]

The range of Poisson ratio accessible using conductive elastomers defines a set of function \((f_i^//, f_i^\perp)\) whose linear combination defines the full space of resistance-strain relationship attainable. The homogeneous isotropic criterion is, however, not validated for a number of stretchable composites, such as those based on carbon nanotubes or silver nanowires, which lead to more complex resistance-strain relationships. This indicates that the dimensionality of the resistance-strain behavior space group could be further extended, a point that is further developed in Fig. 4. Using Eq. 3, we proceed to evaluate the path resistance associated to the two shortest paths of the line array microstructure shown in Fig. 3 (A and B).

These two individual resistive paths let through a different amount of current, which varies with elongation. At 0%, both contribute at the same level to the overall sample resistance (same cost in Yen’s shortest path algorithm). When stretched, the resistance associated to the second shortest path set is largely reduced, whereas the resistance associated to the first shortest path increases (see Fig. 3A, top left and bottom left). To take into account the contribution of both path sets to the total resistive behavior, each path is considered as a resistor assembled in parallel between the two contacts, with respective resistance \( R_{\text{Path } 1} \) and \( R_{\text{Path } 2} \) yielding the equivalent shortest path resistance \( R_{SP} \)

\[
R_{SP} = \left( \sum_{j=1}^{n} R_{\text{Path } j} \right)^{-1} \tag{4}
\]

Figure 3 (B to D) compares the relative equivalent resistance obtained by shortest path method and by the direct matrix inversion method. In Fig. 3B, we compare the resistance-strain relationship from direct calculation (full red line) and by the shortest path method considering (i) the first shortest path (green dashed line, single path), (ii) the second shortest path (blue dashed line, single path), and (iii) the parallel assembly of the first and second shortest path (red dashed line) set based on the combination of a single path of
Reverse engineering of resistance-strain responses

In Fig. 3E, we detail the working principle of the reverse problem algorithm, which determines which set of microstructure and materials can yield a desired resistance-strain relationship (labeled “target response” on the bottom graph). Given an initial library of microstructures (each with a set of associated shortest paths) and materials (resistance-strain relationship for the homogeneous material), a set of resulting responses (labeled “fitted response” on the bottom graph) can be determined for each microstructure and material combination. The predictions provided by the shortest path approach are, however, validated for sufficiently high conductivity ratios (Fig. 3D). This directly relates to the closed channel assumption. As highlighted in Fig. 3 (B to D), this approach provides a reasonable estimation of resistance-strain relationship for a broad range of periodic structures. For structures where the shortest path at 0% and 50% strain are identical, the reasoning can more simply be limited to a combination of shortest paths at 0% strain.

Fig. 2. Influence of structure on electromechanical response. All structures are simulated on the basis of adimensional geometries. Relative resistance change as a function of strain for the respective bi-conductive structures shown in the inset using direct calculation method. The deformation direction is indicated by arrows, and the contacts are indicated at the edges of the microstructure schematic in dark brown. (A) Investigation of three distinct structures with an identical highly conductive square element: (i) regular square array, (ii) shifted square array, and (iii) rotated square array. The light red (resp. dark red) in the inset schematic denotes the high (resp. low) conductivity regions. Top figures correspond to stretching parallel to tensile strain, while bottom figures correspond to the associated compression perpendicular to the elongation axis. (B) Electromechanical response of periodic line array with an increase in conductivity ratio γ from 10 to 5000. Lines are of fixed length and width, with an aspect ratio of 5. (C) Electromechanical response of a periodic line array with a variation in the ratio X/P, where X is the spacing between periodic lines along the tensile axis and P is the period along the strain axis. The conductivity ratio is set at 500.

The accuracy of the method can further be refined using direct resistance calculation, if necessary, once the shortest path approach has narrowed down the search of potential candidates. The match between fitted and target response is largely determined by the degree of freedom provided by the input materials and microstructures. In this work, we show that linear target responses can be accurately fitted using solely materials with a classic linear gauge factor of 2. However, one could also envision fitting nonlinear responses, provided that the materials library is expanded to include, for instance, near-percolation materials such as carbon nanotubes or silver nanowire networks.

Using this same category of materials and all the microstructures presented in Figs. 1 to 3, we apply this selection algorithm to identify the combination providing the most constant resistance-strain response, imposing a conductivity ratio in the range spanning from 1 to 5000. The results indicate that all linear arrays (e.g., microstructures shown in Figs. 2, B and C, 3, B and D, and 4, B and D) are potentially suitable candidates while eliminating other microstructures. Focusing now on the microstructure used in Fig. 3 (B and D), the reverse problem algorithm (shortest path preselection followed by direct calculation refinement) converges toward a constant resistance response with strain for an optimal conductivity ratio γ = 208 using solely shortest path preselection, and further converges to γ = 510 using the direct calculation refinement method. The following section deals with the experimental implementation of a constant resistance response based on this set of parameters (microstructure and conductivity ratio).
Fig. 3. Shortest path method and perspectives. (A) Schematic illustrating the different shortest paths (green and blue arrows) preferentially taken by the current at 0% elongation. (B) Calculation of resistance-strain relationship by direct calculation for the whole assembly (red dashed line) and by shortest path method using only the dominant shortest path at 0% strain and 50% strain (green and blue dashed lines, respectively). Combining shortest path at 0% and 50% strain as a set of parallel resistors (light red dashed line) according to Eq. 4 provides a good agreement with the direct calculation. All calculations are done with a fixed conductivity ratio of 500. (C) Variation of the ratio $\gamma/P$, where $\gamma$ is the width of periodic highly conductive rectangles of fixed length and spacing, and $P$ is the period along the tensile axis. The conductivity ratio is fixed to 500. Dashed lines indicate the results obtained through shortest path method, and the solid lines indicate the results from direct calculation. (D) Difference between relative resistance obtained through direct calculation and shortest path method for the structure shown in the inset, with a conductivity ratio increase from 10 to 500. (E) Schematic illustrating the working principle of the reverse problem: starting from an initial library of microstructures (shortest paths) and materials (resistance-strain relationship for the individual materials), a resulting response (fitted response on the bottom graph) for a microstructure combining two distinct materials can be determined at low computational cost. Scanning through the possible combinations of materials and microstructures, we minimize the deviation between fitted and target response using the determination coefficient $R^2$. **Stable stretchable interconnects using a single microtextured material**

The study has thus far focused on periodic surfaces using two different conductivities. This can straightforwardly be achieved using two materials with distinct electrical properties. This is particularly interesting given the wealth of resistance-strain relationships available for different families of stretchable conductive materials. An alternative consists of using a single stretchable conductive material but with engineered modulations in thickness, which can be equivalently seen as a system with two distinct conductivities and one identical thickness. Previous works have demonstrated how textures can be used to control sophisticated optical properties (30, 31). Inspired by these findings, we rely here on texture to tune electrical properties. These textured systems using a single material presents two advantages: (i) it allows validation of the reverse engineering approach proposed above and (ii) it demonstrates how simple the experimental implementation can be. We proceeded by coating eutectic gallium-indium (E-GaIn) alloy onto a textured polydimethylsiloxane (PDMS) substrate. The textured PDMS is coated with a thin (60 nm) interfacial layer of gold to allow proper wetting of E-GaIn (9). By successive adsorption (see Methods), the thickness of the zone between pits, labeled $t_1$, can be tailored, while the film thickness within the pits, labeled $t_2$, can be in first approximation considered constant. Gradually reducing the value of $t_1$ (or equivalently gradually increasing the conductivity ratio $\gamma$) gives rises to the wide range of resistance-deformation curves (see Fig. 4, C and D, for results and section S7 for experimental details). Using direct resistance calculations, a fitted conductivity ratio $\gamma_{\text{fit}}$ can be associated to each thickness $t_1$. The experimental measurements of relative resistance change with strain in all three cases are reasonably in line with the results obtained from direct calculations. Using the shortest path methodology, the mechano-responsive behavior of line arrays can be predicted with an accuracy below 6% for $\gamma_{\text{fit}} = 1300$ and $\gamma_{\text{fit}} = 475$. However, $\gamma_{\text{fit}} = 120$ shows a stronger deviation between the shortest path approach and direct calculations as well as experimental measurements. This can be linked to the previous observations of Fig. 3D, which demonstrated that the shortest path approach becomes less accurate as the conductivity ratio is decreased (see section S6 for a more thorough analysis). We now turn to the relative evolution of the initial resistance at 0% strain (labeled $R_0$) associated to the various conductivity ratios ($\gamma_{\text{fit}} = 120$, 475, and 1300), using (i) the experimentally measured $R_0$ and (ii) the resistance obtained through direct calculations. To facilitate comparison, results are normalized with respect to $R_0$ for $\gamma_{\text{fit}} = 120$, as shown in Fig. 4C. The change in the initial resistance follows a similar trend between experimental and calculated data. This good overlap between
experimental and simulated data highlights the validity of the proposed model. Besides the random structures from (18), this constant resistance behavior has never been demonstrated to our knowledge at extended deformations (>~30%), and moreover with intrinsically stretchable materials. Given the high conductivity of liquid metals compared with other state-of-the-art stretchable composites such as embedded silver nanowire networks (32), the proposed approach enables the design and fabrication of microstructures with both tailored response and reduced size footprint, a critical point given the increasing miniaturization of integrated systems. One must, however, note that experimental measurements presented here have been taken in the release phase (from 50% to 0% strain). Cracks appear in the thinner regions under elongation beyond 20% strain, which call for novel single material schemes for a generalized implementation.

We have shown how, by solely resorting to thickness modulation with a single conductive material, one can engineer tailored conductivity ratios. Combining thickness modulation with materials of distinct conductivities also provides additional design flexibility. If an identical thickness is imposed, the integration of distinct materials would require a precise conductivity ratio that could only be obtained by a careful choice of intrinsic material conductivities. Resorting to thickness modulation offers an additional lever in design, allowing the integration of materials whose sole intrinsic conductivity ratio may not be sufficient to meet design requirements.

**Extension to three conductive stretchable materials**

To provide additional degrees of freedom, this concept of controlled electrical response in stretchable systems can be extended to more than two materials. Using near-percolation composites, we show here that resorting to three distinct materials allows a much wider set of resulting resistance-strain curves, in particular non-bijective relationships. In Fig. 4E, we propose a theoretical microstructure using three materials selected from the literature materials to create a non-bijective response. We select materials A and B that follow the traditional Ohm’s law with a gauge factor of 2, while the composite material shows a strong increase in resistance typically associated to near-percolation systems. The behavior of composites 1 and 2 is based on (33). (Bottom) Relative change in resistance for the corresponding assembly.

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**Fig. 4. Experimental validation of the model and perspectives for nonlinear response.** (A) Schematic of the experimental sample implemented. The modulation in thickness defines an equivalent conductivity ratio between the different regions of the sample. (B) Optical image showing the textured PDMS with liquid metal, seen from the texture side. Scale bar, 400 μm. (C) Relative change in initial resistance for different fitted conductivity ratios γ. The experimental trend observed is in line with predictions from direct calculations. (D) Relative change in resistance with strain for liquid metal films of decreasing thickness t₁ and nearly constant thickness t₂ (i.e., increasing conductivity ratio γ). Using direct calculations, a corresponding fitting conductivity ratio γ_fit can be associated to each sample. Shortest path calculations using γ_fit allow proper estimation of the experimental behavior for sufficiently large conductivity ratios. (E) (Top) Schematic of an architecture combining three materials (named A, B, and C), with respective (relative) initial conductivities 10⁴, 1, and 1. (Middle) Representation of the resistance response under strain of the three materials taken individually. Material A and B follow the traditional Ohm’s law with a gauge factor of 2, while the composite material shows a strong increase in resistance typically associated to near-percolation systems. The behavior of composites 1 and 2 is based on (33). (Bottom) Relative change in resistance for the corresponding assembly.
factor of 2 (Fig. 4E, middle). Material A is composed of Ag nanowires embedded into a PDMS matrix [$\gamma_{\text{AgNW}} \sim 1.8 \times 10^{-5} \text{ S cm}^{-1}$, based on (31)], while material B is made of carbon black dispersed into a PDMS matrix [$\gamma_{\text{CB}} \sim 1.7 \times 10^{-2} \text{ S cm}^{-1}$, based on (33)]. For composite C, we select a carbon nanotube/fluoro-elastomer with a double percolated network based on (34) ($\gamma_{\text{C1}} \sim 1.4 \times 10^{-2} \text{ S cm}^{-1}$ and $\gamma_{\text{C2}} \sim 3.3 \times 10^{-6} \text{ S cm}^{-1}$; see Fig. 4E, middle). Using an identical thickness for materials A, B, and C provides approximately the same relative conductivity ratios given in Fig. 4E (10, 1, and 1, respectively). Because C2 is much less conductive, the thickness should be largely increased with respect to materials A and B to provide the same relative conductivity ratios. By direct calculation using the 2D resistor network model, we evaluate the evolution of such a microstructure under elongation. The microstructure using composite C1 shows a nearly sinusoidal response (Fig. 4E, bottom). Similarly, composite C2 shows a non-bijective response, but with a sharper transition between positive and negative values. By gradually shifting the composite’s percolation threshold in consecutive linear features, one could envision a sinusoidal function that would extend beyond a single period. This could open up novel applications for sensing or soft robotics, allowing a system to come back through a given state with multiple input values simply relying on a material’s microstructure. Cyclically stretching such an assembly could, for instance, provide a periodic electrical signal with a well-defined increased frequency, effectively acting as an electromechanical frequency converter. The use of near-percolation materials could also allow design of switches with a constant response in strain until an engineered threshold, where the response either sharply decreases or increases, thereby enabling interesting possibilities in sensing, monitoring, or drug delivery.

In summary, periodic electrical designs in stretchable systems create new design opportunities in stretchable electronics, including a broad range of interconnects with tunable resistance-deformation curves. With the combination of modeling based on heterogeneous 2D resistor networks and experimental measurements at different length scales, we show that the periodic microstructure and conductivity ratio determines the fundamental electrical response. Using shortest path algorithms, we show that, given an initial library of materials and microstructures, a combination of these two elements providing optimal fit with a target resistance-strain curve can be identified at low computational cost. We further show that this approach can be simply implemented experimentally using a single textured conductive material. Last, we demonstrate by simulation the possibility to obtain non-bijective resistance-stain responses by combining up to three different materials. This study hence defines a general relationship between microstructure, mechanics, and electrical response that is broadly relevant to stretchable materials engineering.

**METHODS**

**Liquid metals used**

E-GaIn alloy used in this work was obtained from Goodfellow, UK (purity: 99.99%; melting point: 15.5°C).

**Master mold for PDMS imprinting**

SU-8 resin (GM-1075, Gersteltec, Switzerland) was spin-coated at 1030 rpm for 50 s onto a clean Si wafer. The soft bake was done over 1 hour at 120°C using a 4°C/min ramp. The SU-8 film was then exposed using a dedicated Cr-Mask and a Mask Aligner (MA6-Gen3, Süss MicroTec, Germany), using a dose of 528 mJ/cm². Post-exposure bake was done for 2 hours at 90°C. Development was done using Poly(ethylene glycol) methyl ether acrylate (PEGMEA) for 3 min and further rinsed using isopropanol for 2 min. The resulting SU-8 pillars were silanized using trichloro-(perfluorooctyl)silane (Sigma-Aldrich, USA). Textured PDMS substrates were made by drop-casting SYLGARD 184 (Dow Chemical) over the previously described SU-8 structures, using a 10:1 monomer/curing agent ratio. The PDMS was placed under vacuum for 20 min before the curing step at 80°C for 24 hours.

**Simulations**

Both the shortest path method and direct calculation were implemented in a customized code developed in Wolfram Mathematica. A detailed presentation of the practical implementation of the code is presented in the Supplementary Materials.

**Resistance measurements**

The resistance was measured using a four-probe measurement setup and a fixed current of 1 mA. This allowed to neglect contact resistance, which was non-negligible in the case of our experimental implementation (see Fig. 4). The contacts were made of thin copper wires (copper resistivity of $1.7 \times 10^{-8}$ ohm·m, compared to E-GaIn alloy resistivity of $2.9 \times 10^{-7}$ ohm·m based on (1)), which were taped two by two (I+/V+ and V−/I−) spaced by 2 mm in both cases. These two sets of probes were then manually brought into contact with the sample. All probes were placed in the substrate plane, and perpendicular to the texture lines, to reproduce the infinite conductivity contacts of simulations (see Figs. 2 and 3, brown contact lines). The voltage probes were each time placed at the onset of the texture to ensure proper positioning.

**Stretching tests**

Strain was introduced using the setup described in fig. S11. Mechanical clamps held the ends of the PDMS substrate in place. Extra PDMS layers were placed at the interface between the metal clamps and the PDMS substrate to mitigate risks of tearing during elongation. Screws placed at both ends of the setup allowed to precisely tune the substrate elongation (0.5 mm per turn). The experimental measurements shown in Fig. 4 were done using a fixed area of 25 mm × 5 mm, where the length was measured between the sensing probes. All stretching tests were ran starting from 50% elongation and finished at 0% deformation to avoid cracking of the thinner film. To gradually remove liquid metal from the substrate and hence gradually reduce thickness, a successive adsorption technique was developed. A metal syringe was passed over the metal film (side of syringe against the surface of the sample). The syringe tip could wet, as well the liquid metal. The liquid metal adsorbed on the syringe after one pass was simply wiped away, removing in this way a relatively constant amount of material per pass. The three measurements for a given conductivity ratio were done consecutively, without removing the liquid metal adsorbed on the syringe between the consecutive measurements. The error bars of the absolute resistance value $R_0$ at 0% strain (see Fig. 4C) were obtained by averaging the results from the three consecutive measurements. The error bars for deformation were obtained by averaging the resistance deviation derived for the three consecutive tests.

**SUPPLEMENTARY MATERIALS**

Supplementary material for this article is available at http://advances.sciencemag.org/cgi/content/full/7/27/eabf7558/DC1
REFERENCES AND NOTES


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